

FIG. 1 (PRIOR ART)

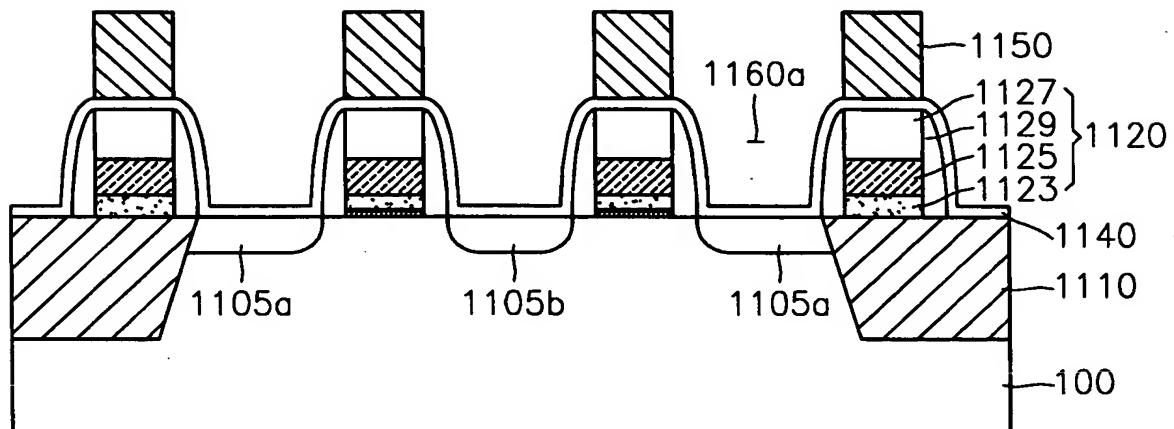


FIG. 2 (PRIOR ART)

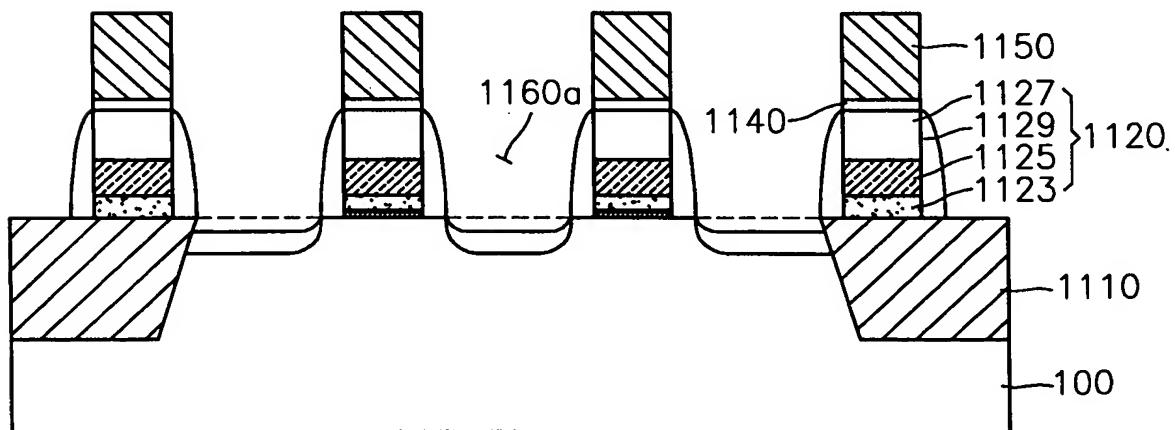


FIG. 3

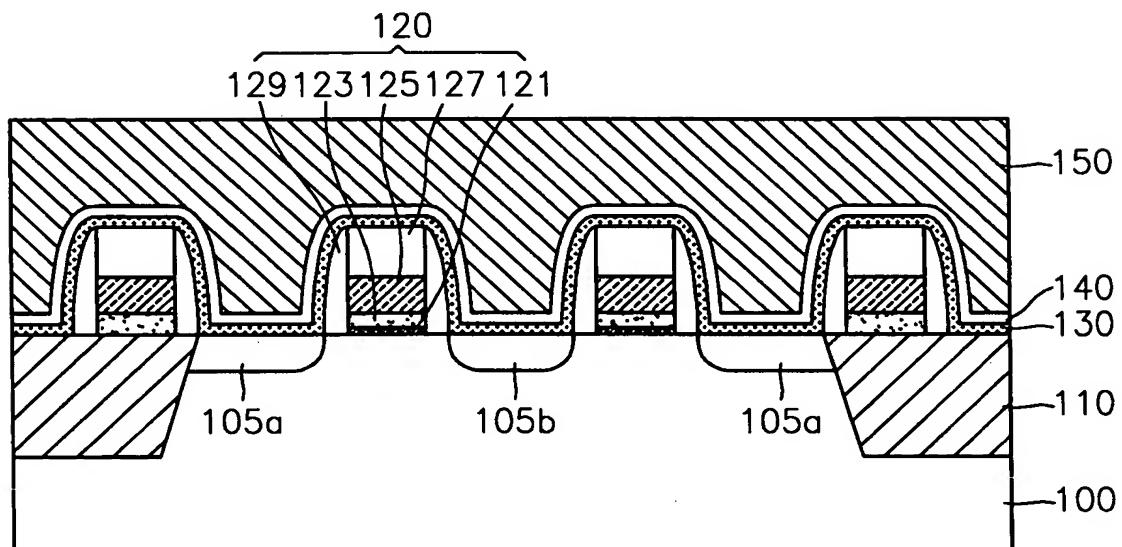
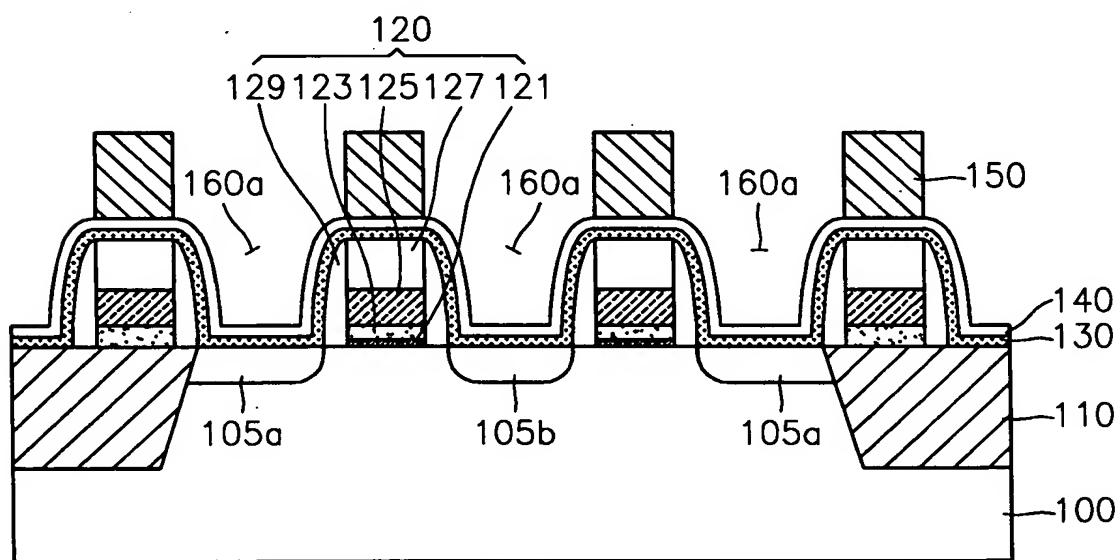


FIG. 4



“Method Of Forming A Contact In A Semiconductor Device”
Appln. No. [New] – Attny. Doc. No. SEC.1063
Inventors: Yong-joon CHO et al.

FIG. 5

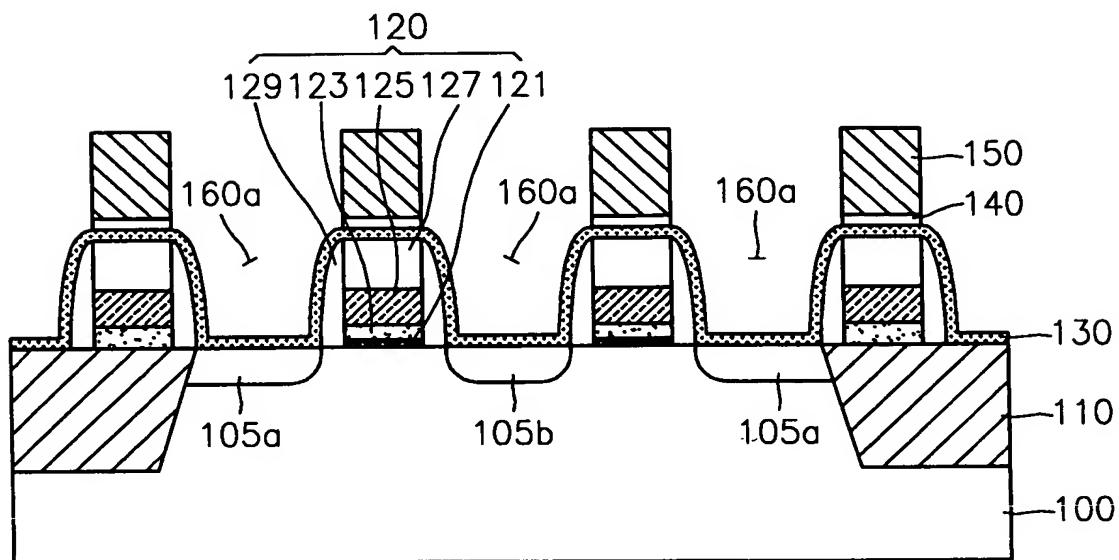


FIG. 6

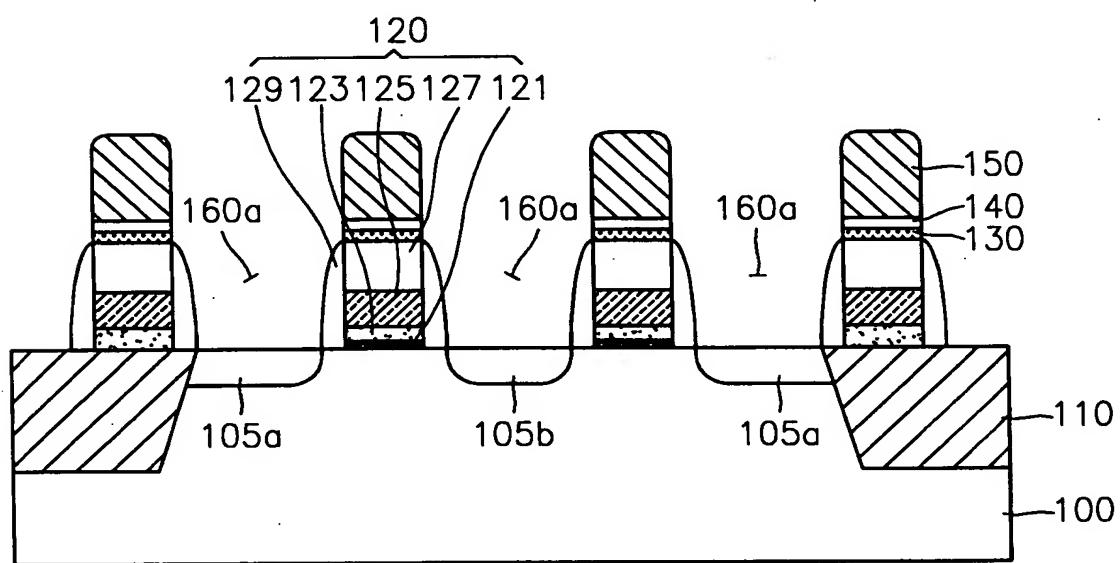


FIG. 7

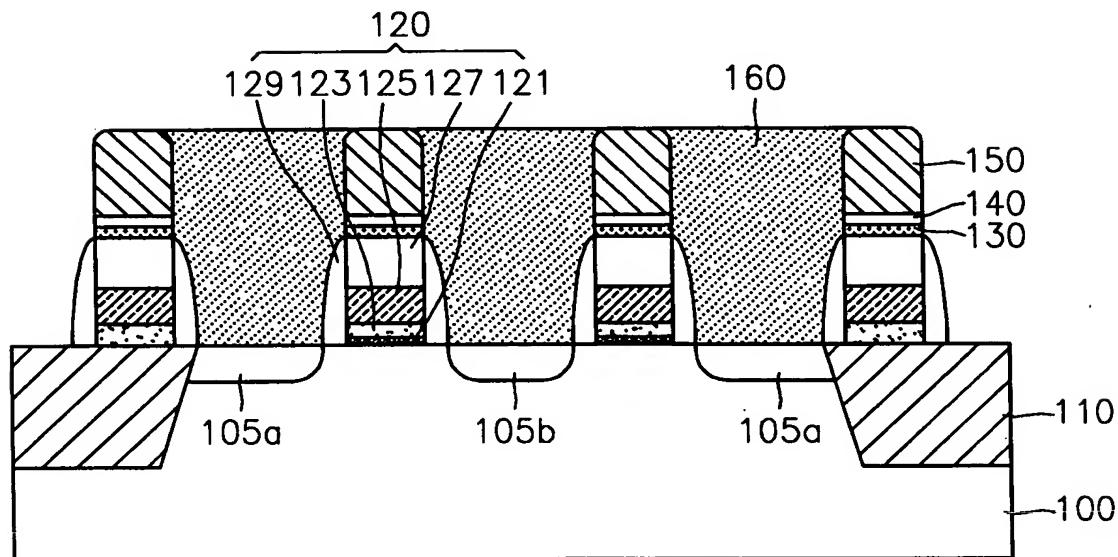


FIG. 8

